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Author Correction: DNA damage and somatic mutations in mammalian cells after irradiation with a nail polish dryer.

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The original version of this Article contained an error in the Abstract, which incorrectly read ‘However, no experimental evaluation has been conducted to reveal the effect of radiation emitted by UV-nail polish dryers on mammalian cells.’ The correct version replaces this sentence with ‘However, the effect of radiation emitted by UV-nail polish dryers on the physiology and mutagenesis of mammalian cells remains unclear.’. This has been corrected in both the PDF and HTML versions of the Article.

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